47%

2-4

<1

1.94

6 months

3 months

-40 to 100 °C



# LuxNIL<sup>®</sup> P288-U

# High refractive index UV curable dispersion in PGMEA

Viscosity at 25 °C, mPa.s or cps

Pot life or working life (20 - 30°C):

Refractive index of cured film (25 °C)

FEATURES: High Refractive Index, EXCELLENT adhesion to plastic and glass substrates, OPTICALLY Clear

**TYPICAL PROPERTIES** 

Shelf life (20 - 30°C):

Shrinkage (volume, %)

@589 nm

Operating temperature:

Uncured resin Solid content:

Cured film

### PRODUCT DESCRIPTION:

- LuxNIL<sup>®</sup> P288-U is a UV-curable inorganic organic dispersion in PGMEA that is suitable for AR/VR/MR applications.
- Base chemistry: Inorganic nano particles in acrylate binder.

#### PRODUCT USE:

- Diffractive Optical Elements (DOE)
- AR/VR/MR
- Photo Nano-Imprint Lithography (P-NIL)

#### PROCESS FLOW



# LuxNIL<sup>®</sup> P288-U OPTICAL PROPERTIES

| Properties       | LuxNIL®P288-U |
|------------------|---------------|
| n <sub>589</sub> | 1.94          |
| Transmission*§   | 86%           |
| Haze*            | 0.2%          |
| Clarity*         | 100%          |
|                  |               |

\*1 micron film on borosilicate glass. <sup>§</sup>No correction for surface reflection

# **APPLICATION NOTES:**

**PROCESS:** 

1) Coating step for film forming: LuxNIL<sup>®</sup> P288-U is used as a nano imprint lithography resin. LuxNIL<sup>®</sup> P288-U can be applied by spin coat, roll coat, or gravure coat.

the original container is require

- 2) Solvent removing step: after coating, heat is applied at 70 to 90 °C for 60 sec to remove PGMEA. Due to high dispersion loading, for best imprints, solvent removal at 70 80 °C for 60 sec is suggested.
- 3) Nano-imprint-lithography: replication of nano features with a working stamper is conducted. <u>Pressure might be</u> required for imprint process.
- 4) UV cure: UV cure to fix the nano features.
- 5) Working stamp is removed.
- 6) <u>Final heat conditions at 150 °C for 4 hrs after imprint step will help remove all residual solvent, and full refractive index can be obtained.</u>

## Suggested coating thickness for LuxNIL® P288-U: 1,000 to 2,000 nm

## UV CURING CONDITIONS:

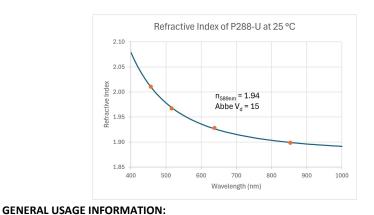
\*Metal halide/medium or high Mercury UV: <u>UV-A (320-400 nm)</u>, intensity: 100-1,000 mW/cm<sup>2</sup> \*or <u>LED-365 nm</u>, UV light intensity: 100 to 1,000 mW/cm<sup>2</sup> LuxNIL<sup>®</sup> P288-U should be <u>cured between two substrates</u> or in an inert atmosphere.

# RECOMMENDED UV Conditions: LED-365 nm, 250 mW /cm<sup>2</sup> x 100 to 200 sec. Cure is done between 2 substrates or in an inert atmosphere.

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# LuxNIL<sup>®</sup> P288-U RI vs wavelength



Storage: After receipt in amber HDPE bottles, room temperature storage (15-30°C) in